

In the claims

Cancel claims 1-29 and add new claims 30-46.

Claims 1-29 (canceled)

1 30. (New) A method of making a horizontal magnetic head having an air
2 bearing surface (ABS), comprising:
3 forming at least one coil layer and an insulation stack with the coil layer being embedded
4 in the insulation stack;
5 forming said at least one coil layer with a filament which spirals in a plane which is
6 parallel to said ABS;
7 forming first and second pole pieces with the insulation stack sandwiched between the first
8 and second pole pieces;
9 forming the first pole piece with a first horizontal component which is partially bounded
10 by first and second major planar thin film surfaces joined by a first edge with the first major planar
11 thin film surface of the first horizontal component forming a portion of the ABS;
12 forming the second pole piece with a second horizontal component which is partially
13 bounded by first and second major planar thin film surfaces joined by a second edge with the first
14 major planar thin film surface of the second horizontal component forming a portion of the ABS;
15 forming a write gap layer between said first and second edges;
16 forming a first shield layer having first and second major planar thin film surfaces joined
17 by a third edge with the first major planar thin film surface of the first shield layer forming a
18 portion of the ABS; and
19 forming a magnetoresistive (MR) sensor and first and second gap layers with the MR
20 sensor sandwiched between the first and second gap layers and the first and second gap layers
21 located between the third edge and the first horizontal component and with the MR sensor and the
22 first and second gap layers forming portions of the ABS.

1 31. (New) A method as claimed in claim 30 comprising:
2 forming an insulation layer between the MR sensor and the first pole piece.

1 32. (New) A method as claimed in claim 30 comprising:
2 said forming of the first horizontal component forming the first horizontal component with
3 a fourth edge which interfaces the second gap layer so that the first horizontal component serves
4 as a second shield layer for the MR sensor.

1 33. (New) A method as claimed in claim 30 comprising:
2 forming the MR sensor with an active region wherein the active region has a width which
3 defines a read track width;
4 forming each of the first and second horizontal components with a width at said write gap
5 layer which defines a write track width; and
6 aligning the widths of the active region and the first and second horizontal components.

1 34. (New) A method as claimed in claim 30 comprising:
2 forming the MR sensor with only one elongated MR stripe which has a longitudinal axis
3 with the longitudinal axis extending perpendicular to said ABS.

1 35. (New) A method of making a horizontal magnetic head having a planar
2 head surface for facing a moving magnetic medium, comprising the steps of:

3 forming at least one coil layer and an insulation stack with the coil layer being embedded
4 in the insulation stack;

5 forming said at least one coil layer with a filament which extends about a central axis in
6 a continuously receding fashion so as to form a spiral which lies in a pancake fashion in a coil
7 plane which is parallel to said planar head surface and wherein the central axis is perpendicular
8 to said planar head surface and said coil plane;

9 forming first and second pole pieces with the insulation stack sandwiched between the first
10 and second pole pieces;

11 forming the first pole piece with a first horizontal component which is partially bounded
12 by first and second major planar thin film surfaces joined by a first edge with the first major planar
13 thin film surface of the first horizontal component forming a portion of the planar head surface;

14 forming the second pole piece with a second horizontal component which is partially
15 bounded by first and second major planar thin film surfaces joined by a second edge with the first
16 major planar thin film surface of the second horizontal component forming a portion of the planar
17 head surface;

18 forming a write gap layer between said first and second edges;
19 forming a first shield layer having first and second major planar thin film surfaces joined
20 by a third edge with the first major planar thin film surface of the first shield layer forming a
21 portion of the planar head surface; and
22 forming a magnetoresistive (MR) sensor and first and second gap layers with the MR
23 sensor sandwiched between the first and second gap layers and the first and second gap layers
24 located between the third edge and the first horizontal component and with the MR sensor and the
25 first and second gap layers forming portions of the planar head surface.

1 36. (New) A method as claimed in claim 35 comprising:
2 forming an insulation layer between the MR sensor and the first pole piece.

1 37. (New) A method as claimed in claim 35 comprising:
2 said forming of the first horizontal component forming the first horizontal component with
3 a fourth edge which interfaces the second gap layer so that the first horizontal component serves
4 as a second shield layer for the MR sensor.

1 38. (New) A method as claimed in claim 35 comprising:
2 forming the MR sensor with an active region wherein the active region has a width which
3 defines a read track width;
4 forming each of the first and second horizontal components with a width at said write gap
5 layer which defines a write track width; and
6 aligning the widths of the active region and the first and second horizontal components.

1 39. (New) A method as claimed in claim 35 comprising:
2 forming the MR sensor with only one elongated MR stripe which has a longitudinal axis
3 with the longitudinal axis extending perpendicular to said planar head surface.

1 40. (New) A method of making a horizontal magnetic head having a planar
2 head surface, comprising the steps of:
3 forming at least one coil layer and an insulation stack with the coil layer being embedded
4 in the insulation stack;

5 forming first and second pole pieces with the insulation stack sandwiched between the first
6 and second pole pieces;

7 forming the first pole piece with a first horizontal component which is partially bounded
8 by first and second major planar thin film surfaces joined by a first edge with the first major planar
9 thin film surface of the first horizontal component forming a portion of the planar head surface;

10 forming the first pole piece with a first recessed horizontal component which is recessed
11 from and extends parallel to the planar head surface;

12 forming the first pole piece with a slanted component which extends at an angle to the
13 ABS and joins the first recessed horizontal component and the first horizontal component;

14 forming the second pole piece with a second horizontal component which is partially
15 bounded by first and second major planar thin film surfaces joined by a second edge with the first
16 major planar thin film surface of the second horizontal component forming a portion of the planar
17 head surface;

18 forming a write gap layer between said first and second edges;

19 forming a first shield layer having first and second major planar thin film surfaces joined
20 by a third edge with the first major planar thin film surface of the first shield layer forming a
21 portion of the planar head surface;

22 forming a magnetoresistive (MR) sensor and first and second gap layers with the MR
23 sensor sandwiched between the first and second gap layers and the first and second gap layers
24 located between the third edge and the first horizontal component and with the MR sensor and the
25 first and second gap layers forming portions of the planar head surface; and

26 forming an insulation layer between the MR sensor, the first and second gap layer, the first
27 shield layer, the first horizontal component and the first recessed horizontal component so as to
28 separate the MR sensor, the first and second gap layers, the first shield layer and the first
29 horizontal component from the first recessed horizontal component.

1 41. (New) A method as claimed in claim 40 comprising:

2 forming the MR sensor with an active region wherein the active region has a width which
3 defines a read track width;

4 forming each of the first and second horizontal components with a width at said write gap
5 layer which defines a write track width; and

6 aligning the widths of the active region and the first and second horizontal components.

1 42. (New) A method as claimed in claim 41 comprising:

2 said forming of the first horizontal component forming the first horizontal component with
3 a fourth edge which interfaces the second gap layer so that the first horizontal component serves
4 as a second shield layer for the MR sensor;

5 forming the second pole piece with a second recessed horizontal component which is
6 recessed from and extends parallel to the ABS; and

7 joining the second horizontal component to the second recessed horizontal component with
8 the second major planar thin film surface of the second horizontal component overlapping and
9 interfacing the first major planar thin film surface of the second recessed horizontal component.

1 43. (New) A method of making a horizontal magnetic head having a flat planar head
2 surface, comprising the steps of:

3 forming at least one coil layer and an insulation stack with the coil layer being embedded
4 in the insulation stack;

5 forming said at least one coil layer with a filament which spirals in a flat coil plane which
6 is parallel to said flat planar head surface and about a central axis which is perpendicular to said
7 flat planar head surface and said flat coil plane;

8 forming first and second pole pieces with the insulation stack sandwiched between the first
9 and second pole pieces;

10 forming the first pole piece with a first horizontal component which is partially bounded
11 by first and second major planar thin film surfaces joined by a first edge with the first major planar
12 thin film surface of the first horizontal component forming a portion of the flat planar head
13 surface;

14 forming the second pole piece with a second horizontal component which is partially
15 bounded by first and second major planar thin film surfaces joined by a second edge with the first
16 major planar thin film surface of the second horizontal component forming a portion of the flat
17 planar head surface;

18 forming a write gap layer between said first and second edges;

19 forming a first shield layer having first and second major planar thin film surfaces joined
20 by a third edge with the first major planar thin film surface of the first shield layer forming a
21 portion of the flat planar head surface; and

22 forming a magnetoresistive (MR) sensor and first and second gap layers with the MR
23 sensor sandwiched between the first and second gap layers and the first and second gap layers
24 located between the third edge and the first horizontal component and with the MR sensor and the
25 first and second gap layers forming portions of the flat planar head surface.

1 44. (New) A method as claimed in claim 43 comprising:
2 forming the first pole piece with a first recessed horizontal component which is recessed
3 from and extends parallel to the flat planar head surface;
4 forming the first pole piece with a slanted component which extends at an angle to the flat
5 planar head surface and joins the first recessed horizontal component and the first horizontal
6 component; and
7 forming an insulation layer between the MR sensor, the first and second gap layer, the first
8 shield layer, the first horizontal component and the first recessed horizontal component so as to
9 separate the MR sensor, the first and second gap layers, the first shield layer and the first
10 horizontal component from the first recessed horizontal component.

1 45. (New) A method as claimed in claim 44 comprising:
2 forming the MR sensor with an active region wherein the active region has a width which
3 defines a read track width;
4 forming each of the first and second horizontal components with a width at said write gap
5 layer which defines a write track width; and
6 aligning the widths of the active region and the first and second horizontal components.

1 46. (New) A method as claimed in claim 45 comprising:
2 said forming of the first horizontal component forming the first horizontal component with
3 a fourth edge which interfaces the second gap layer so that the first horizontal component serves
4 as a second shield layer for the MR sensor;
5 forming the second pole piece with a recessed horizontal component which is recessed
6 from and extends parallel to the flat planar head surface; and
7 joining the second horizontal component to the second recessed horizontal component with
8 the second major planar thin film surface of the second horizontal component overlapping and
9 interfacing the first major planar thin film surface of the second recessed horizontal component.